DEFECTS INDUCED BY ELECTRON IRRADIATION IN CdSe THIN FILMS

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Thin films of AIIBVI compounds are potential candidates for the manufacturing of electronic and optoelectronic devices, especially solar cells. In this paper the effects of irradiation with high-energy electrons on structural and electrical properties of CdSe thin films have been investigated. The films, 30 μm thick, were prepared by thermal-vacuum evaporation on glass substrate at a temperature of 220 °C. The samples were irradiated with 6-MeV electrons, up to a fluency of 10^{14} e/cm². XRD investigation has revealed that the films contain wurtzite-type CdSe, (001) preferentially oriented in the growth direction. The defects induced by electron irradiation have been studied using the Space Charge Limited Currents (SCLC) measurements and Thermally Stimulated Currents (TSC) spectroscopy. It was found that the electrical conduction of the samples, both before and after irradiation, is mainly controlled by a defect having an energy level located at 0.38 eV below the conduction band edge, its density was significantly increased as a result of irradiation. The possible origin of this defect is discussed.

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Keywords: CdSe, Thin films, Electron irradiation, Defects

1. Introduction

AIIBVI compounds are good candidates for practical applications like solar cells, optical detectors and optoelectronic devices. Among them, cadmium selenide (CdSe) is recommended by a suitable band gap and optical properties as a very promising material for optoelectronic applications like solar cell structures. It is a well-established fact that the performance of the devices based on thin films strongly depends on structural and electronic properties of the films obtained under various experimental conditions. Therefore, the task to identify and to learn how to control the defects having the most important influence on electrical and/or optical properties of the films is very important. Many reports have been published on the electrical properties of vacuum deposited films of CdSe [1-5]. However, little work was done on the influence of the ionizing radiations on their physical properties [6-8]. Given that thin films of AII-BVI compounds, especially CdS, CdSe, CdTe, ZnSe, are potential candidates for producing solar cells used in space technology applications, where the flux of ionizing radiations is high enough, such a study is very important. Irradiation with electrons having energies in MeV range can also be used to investigate simple defects, like vacancies or interstitials, because in this case no massive structural damage is produced. An electron with energy of 1-10 MeV can only produce a small number of atomic displacements [9]. In this paper we present the results of a complex investigation of the changes induced by electron irradiation on the electrical properties of CdSe thin films. Different experimental techniques were used (TSC and SCLC measurements) and the results are discussed. The possible origin of the main defects created by 6-MeV electron is also discussed.

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2. Experimental procedures

CdSe thin films, 30 μm thick, were prepared by thermal vacuum evaporation from a single source onto an optical glass substrate. The pressure in the evaporation cell was kept below $2 \times 10^{-5}$ Torr during the deposition of the films. The evaporator consisted of a quartz container heated to 750 °C, the substrate being maintained at 220°C during the deposition. To improve the structural and chemical homogeneity of the films, they were subsequently thermally treated in vacuum at 300 °C, for 10 min.

Electrical investigations were performed on two types of structures, having respectively gold contacts in a sandwich geometry Au/CdSe/Au and aluminium contacts in a planar geometry. The Au/CdSe/Au sandwich structures were prepared as follows: first a gold strip of 8 mm length, 2 mm width and 300 nm thickness was deposited on a glass plate substrate, then the CdSe film was grown on the gold electrode and, finally, a second gold strip was deposited on the CdSe layer, having the same geometry as the first one but being placed in a perpendicular direction with respect to it. The effective area, formed by the overlap of the electrodes was 0.04 cm², of about one order of magnitude smaller than the area of CdSe film to prevent the edge effects. To improve the stability and ohmicity of the contacts, the structures were thermally treated in air at 250 °C, for 30 min. It is known [10,11] that the gold electrodes prepared in this way guarantee stable and relatively good ohmic contacts on CdSe thin films.

Planar structures were prepared by evaporating four Al contacts on top of CdSe films. The contacts, 1 mm x 1 mm in surface, 0.3 μm thick and separated by 1 mm, were placed in line.

The obtained structures were subjected to irradiation with electrons supplied by a betatron. The samples were irradiated at room temperature with 6-MeV and 7-MeV electrons to a fluence of $10^{13}$ electrons/cm², irradiation direction being perpendicular to the surface of the samples. The thermal effect during irradiation was negligible.

The structure of the samples was investigated, before and after irradiation, with a θ-2θ X-ray diffractometer, using Cu-Kα ($\lambda$=1.54178 Å) line. Line profiles were recorded in a step-scanning regime with $\Delta(2\theta)$=0.05°. The temperature dependence of the electrical resistance and I-V characteristics were recorded by introducing the samples in a nitrogen cryostat or a He closed cycle cryostat and contacting the probes with soft Ag wire. During the measurements the pressure in the cryostat was below $10^{-4}$ Torr. Electrical properties were measured with a Keithley 2400 source-meter or a Philips X-Y recorder, in the temperature range allowed by the experimental setup.

Thermally stimulated current (TSC) analysis was performed after filling the traps by adequate illumination (700 nm light, for 15 min.) at 50 K.

3. Experimental results

3.1. Structure

As revealed by XRD spectra, the films consist of a hexagonal compact (hcp) wurtzite phase, which is known to be the stable one for this material. The films are preferentially oriented with (001) crystalline direction perpendicular to their surface. The position of the peaks yields hcp lattice constants of 4.296Å ($a_h$) and 7.030Å ($c_h$). While $a_h$ is consistent with the reported bulk value, $c_h$ is somewhat larger.

A simple inspection of the diffraction pattern shows that both broadened lines and sharp reflections are present. An explanation for this [12] has been given as due to faulting. In the case of crystals made up of close-packed layers of atoms, stacking faults (mistakes in the normal hexagonal or cubic packing order) may easily occur. The energy of producing such defects is very low. For reflections of the type $(hk0)$, $(00l)$ and $(hkl)$ with $h=\pm 3n$, there is no change in structure factor on crossing the fault, therefore no broadening is observed. In contrast, for $(hkl)$ reflections with $h-k=3n\pm 1$, the structure factor changes significantly at each fault, which results in broadening the line. The amount of broadening depends on the number of stacking faults.
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The coherence lengths $D_{\text{eff}}$, calculated for three samples from (002) peak, are indicated in Table I. $D_{\text{eff}}$ values were obtained using the well-known Scherrer formula:

$$D_{\text{eff}} = \frac{0.9\lambda}{\delta \cos \theta_0},$$

where $\lambda$ is the X-ray wavelength, $\theta_0$ is the angle where the peak occurs and $\delta$ is its full width at half-maximum.

Table 1. Coherence length, as determined from (002) peak.

<table>
<thead>
<tr>
<th>Sample</th>
<th>$D_{\text{eff}}$ (Å)</th>
</tr>
</thead>
<tbody>
<tr>
<td>B1</td>
<td>1072</td>
</tr>
<tr>
<td>B2</td>
<td>1352</td>
</tr>
<tr>
<td>B3</td>
<td>1587</td>
</tr>
</tbody>
</table>

Within the limits of experimental resolution, no change in diffraction pattern aspect or in line broadening was observed following electron irradiation at fluences up to $10^{16}$ electrons/cm$^2$ (Fig. 2). Therefore there are no major changes in the crystalline structure of the films, as a result of electron irradiation at energy and fluences indicated above. It may be concluded that at most point-like defects (vacancies, interstitials or their association in some more complex defects) do occur in the structure of the films.
3.2. Electrical properties

3.2.1. Au/CdSe/Au sandwich cells

The current-voltage characteristics of the Au/CdSe/Au cells, before and after the two sessions of irradiation, are nonlinear and completely symmetrical with respect to the polarity of applied voltage. The Ohm's law is followed at low applied voltage, with a thermally activated conductivity. The temperature dependence of the electrical conductivity is well described by the expression:

$$\sigma(T) = \sigma_1 \exp\left(-\frac{E_{\text{a1}}}{k_B T}\right) + \sigma_2 \exp\left(-\frac{E_{\text{a2}}}{k_B T}\right),$$

(2)

as demonstrated by the plot in Fig.3. The values of the parameters entering eq. (2), as obtained by numerical fit, are indicated in Table 2. The experimental results suggest that there are two competing conduction mechanisms: one of them, with larger activation energy and dominating in the high temperature range, implying carriers in extended band states (conduction band mechanism), the other involving the hopping of the charge carriers over localized states induced by the structural and/or chemical disorder in the bandgap, dominating at low temperatures. The values of $\sigma_1$ and $E_{\text{a1}}$ in Table 2 correspond to the conduction band mechanism, while $\sigma_2$ and $E_{\text{a2}}$ are typical for the hopping mechanism.
After irradiation a shift of the Fermi level towards the conduction band (CB) was observed, as well as an important decrease of the pre-exponential factor $\sigma_1$. The Fermi level is pinned by some defect states of donor type, whose density is strongly affected by irradiation. Using the measured values of $E_{a1}$ and $E_{a2}$, the location of these defect states in the band gap of CdSe can be determined with the following argument. The hopping activation energy $E_{a2}$ is roughly of the order of $|E_0 - E_{F0}|$, where $E_0$ is the energetic separation between the center of the band of defect states and the bottom of CB $E_c$, and $E_{F0}$ is the equilibrium Fermi level, also measured from $E_c$ [13]. In the following all energetic values will be considered with respect to $E_c$, taken as the zero on energy scale (so $E_0$, $E_{F0}$<0). If $E_0 > E_{F0}$ (the center of defect band located between the Fermi level and the bottom of CB), states lying near the Fermi level are very rare, their overlap is weak, and consequently their contribution to the hopping conductivity can be neglected. The main contribution to hopping conduction is due to electrons activated from the Fermi level into the peak of the density of states, so $E_{a2} = E_0 - E_{F0}$, or equivalently, $E_{a2} = E_{a1} - |E_0|$ (see Fig. 4). The same argument holds for the case where $E_0 < E_{F0}$ (the Fermi level located between the center of defect band and the bottom of CB), when the hopping conduction is mainly associated with the motion of the holes over defect states whose energy is close to $E_{F0}$, and $E_{a2} = E_{F0} - E_0$. This seems to be the case after the second irradiation. Comparing the values of $E_{a2}$ and $E_{a1}$ in Table II, a value $E_0$ of about -0.41 eV is obtained. The locations of the defect band and of the Fermi level before and after irradiation are indicated in Fig. 4.

![Fig. 4. Model of defect states band in the band gap of CdSe, as suggested by the analysis of the presented transport data. The irradiation influence on the location of the Fermi level (0- non-irradiated, 1- after first and 2- after the second irradiation) and also on the defect states density (a- non-irradiated, b- after first and c- after the second irradiation) are indicated.](image)

Further insight on the effect of irradiation can be achieved by examining the super-linear region of the I-V characteristics. We interpreted the data in that range, in the frame of space-charge limited currents (SCLC) theory. Accordingly, for a $n$-type material, the electric field $E(x)$ in the sample is given by the Poisson equation [14]:

### Table 2. Parameters describing the electrical properties of the films and the defect band states.

|                    | $\sigma_1$ (\(\Omega^{-1} \cdot \text{cm}^{-1}\)) | $E_{a1}$ = $E_c - E_{F0}$ (eV) | $\sigma_2$ (\(\Omega^{-1} \cdot \text{cm}^{-1}\)) | $E_{a2}$ (eV) | $N_0$ (cm\(^{-3}\)eV\(^{-1}\)) | $|E_0|$ (eV) | $\Delta E$ (eV) |
|--------------------|---------------------------------|--------------------------------|---------------------------------|----------------|-------------------------------|-------------|--------------|
| before irradiation | 514.17                          | 0.46                           | 4.59x10\(^{-6}\)               | 0.048          | 1.09x10\(^{12}\)             | 0.41        | 0.055        |
| after 1\(^{st}\) irradiation | 91.44                          | 0.42                           | 8.54x10\(^{-6}\)               | 0.018          | 3.31x10\(^{12}\)             | 0.41        | 0.052        |
| after 2\(^{nd}\) irradiation | 11.47                          | 0.37                           | 4.69x10\(^{-6}\)               | 0.029          | 5.74x10\(^{12}\)             | 0.41        | 0.052        |
and the current density, constant through the sample, is:

\[ j = e \mu_n \rho(x) \varepsilon(x) = \text{const.} \]  

\[ \text{In eq. (3)} \quad n_0 = N_c \exp \left( \frac{E_{F0} - E_c}{k_BT} \right) \quad \text{and} \quad n_{\text{tr}} \quad \text{are the thermal equilibrium free and trapped carrier density,} \quad n = N_c \exp \left( \frac{E_F - E_c}{k_BT} \right) \quad \text{and} \quad n_t \quad \text{denote the same quantities in the non-equilibrium case, when the carrier injection at the contacts becomes important,} \quad \varepsilon_0 = 8.85 \times 10^{-12} \text{ F/m is the vacuum permittivity,} \quad \varepsilon = 10 \quad \text{is the CdSe dielectric constant}^{14}, \quad e \quad \text{is the electron charge,} \quad E_{F0} \quad \text{is the equilibrium Fermi level given in Table II,} \quad E_F \quad \text{is the non-equilibrium quasi-Fermi level. Considering the effective mass of electrons in CdSe,} \quad m_e = 0.13 m_0, \quad \text{the effective density of states in the conduction band was evaluated as} \quad N_c = \frac{2 \pi m_e k_B T}{h^2} = 0.226 \times 10^{21} T^{3/2} \text{ m}^{-3}. \quad \text{Assuming a set of traps distributed in energy, having some density of states} \quad N_t(E), \quad n_t \quad \text{can be written as:} \]

\[ n_t = \int_{E_v}^{E_C} \frac{N_t(E) \, dE}{E_v + \frac{1}{2} \exp \left( \frac{E - E_F}{k_BT} \right)} = \int_{E_v}^{E_C} \frac{N_t(E) \, dE}{E_v + \frac{n_0}{2n} \exp \left( \frac{E - E_{F0}}{k_BT} \right)} . \quad (5) \]

\[ \text{The same expression holds for} \quad n_{\text{tr}}, \quad \text{with} \quad E_F \quad \text{replaced by} \quad E_{F0}. \quad \text{Using eqs. (3-5), the electrical field in the sample and, subsequently, the voltage across the sample, corresponding to each value of the current density can be calculated, if the analytical function} \quad N_t(E) \quad \text{is known.} \]

\[ \text{In order to interpret the data, we considered a defect band with a Gaussian shape, lying in the vicinity of the Fermi level:} \]

\[ N_t(E) = N_0 \exp \left( \frac{(E - E_{F0})^2}{\Delta E} \right) . \quad (6) \]

\[ \text{A numerical fit procedure was developed for determining the parameters} \quad N_0, \quad E_0 \quad \text{and} \quad \Delta E \quad \text{entering eq. (6). The center of the defect band} \quad E_0 \quad \text{was restricted to} \quad 0.41 \text{ eV below the bottom of the conduction band, following the argument presented above. The I-V characteristics recorded at different temperatures were used (see Fig. 5), the parameters were determined for each of them and the average results are indicated in Table II. For the sake of simplicity only three I-V plots together with the corresponding results of the numerical fit were showed in Fig.5. For comparison purposes the characteristics recorded at about the same temperatures, for non-irradiated and irradiated structures, have been chosen.} \]

\[ \text{As expected, an increase of the defect state density from} \quad 1.09 \times 10^{14} \text{ cm}^{-3} \text{eV}^{-1} \quad \text{for the non-irradiated sample to} \quad 5.74 \times 10^{14} \text{ cm}^{-3} \text{eV}^{-1} \quad \text{after the second session of irradiation was observed. There is no significant change of the width} \quad \Delta E=0.11 \text{ eV of the defect band.} \]
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Fig. 5. Current-voltage characteristics at different temperatures, before (a) and after the first (b) and second (c) irradiation sessions. Both the measured values (points) and the best fits (continuous line) obtained as indicated in text are plotted.

3.2.2. Planar structures

The Arrhenius plot of the measured electrical resistance is shown in Fig. 6. One can easily observe that electron irradiation (6 MeV electrons to a fluency of $5 \times 10^{13}$ electrons/cm$^2$) induced only slight changes in electrical properties, except for temperatures below 90 K. In some temperature ranges, the temperature dependence of the films resistance is well described by:

$$R(T) = R_0(T) \exp \left( \frac{E_a}{k_B T} \right)$$

(7)

where $E_a$ is the activation energy. The pre-exponential factor $R_0$ may have a slight temperature dependence, reflecting, for example, the temperature dependence of free carriers mobility in the case of band conduction mechanism. Table III presents the values of $E_a$ and $R_0$ parameters appearing in eq. (7), as obtained by numerical fit in the indicated temperature ranges. A band conduction mechanism is responsible for the observed electrical properties at room temperature and down to 240 K, controlled essentially by a deep donor level ($D_1$) located at 0.37 eV below the bottom edge of the conduction band. In this region the temperature dependence of the electrical resistance is entirely
due to the rapid decrease in the concentration of the free carriers (electrons), gradually recaptured by the donor levels they originate from. An increase of the pre-exponential parameter, $R_0$, was observed after irradiation, which can be explained by the increase of the density of defect states in the films, and the corresponding decrease of the mobility of the free carriers.

![Graph showing temperature dependence of the electrical resistance of the films, before and after irradiation with 6 MeV, $5 \times 10^{13}$ electrons/cm$^2$.]

One can easily observe more significant changes after irradiation in the low temperature range, below 90 K (Fig. 6). $E_a$ and $R_0$ values in this range, as well as the effect of irradiation, can be explained assuming that the electrical conduction comes from electrons hopping between $D_1$ donor states, partially emptied by compensation. Unlike the room temperature case, the pre-exponential factor $R_0$ drops by almost an order of magnitude after irradiation. This is typical for hopping conduction mechanism, when $R_0$ depends exponentially on the density of localized states involved in the process [13].

Table 3. Parameters characterizing the electrical resistance (eq. (7)), as obtained by numerical fit.

<table>
<thead>
<tr>
<th>Temperature range (K)</th>
<th>$E_a$ (eV)</th>
<th>$R_0$ ((\Omega))</th>
<th>Obs.</th>
</tr>
</thead>
<tbody>
<tr>
<td>300-240</td>
<td>0.37</td>
<td>165.5</td>
<td>as grown sample</td>
</tr>
<tr>
<td></td>
<td>0.37</td>
<td>248.8</td>
<td>irradiated sample</td>
</tr>
<tr>
<td>100-40</td>
<td>0.004</td>
<td>$2.84 \times 10^{11}$</td>
<td>as grown sample</td>
</tr>
<tr>
<td></td>
<td>0.003</td>
<td>$3.87 \times 10^{10}$</td>
<td>irradiated sample</td>
</tr>
</tbody>
</table>

TSC spectra analysis, performed both before and after irradiation, allowed us to obtain a more detailed quantitative information on the effect of electron irradiation on the films. A well resolved TSC peak, originating from thermal release of charge carriers from a trap having activation energy $E_{t0}$ into conduction or valence band, is described by [15]:

$$I_{TSC}(T) = I_0 \exp \left\{ - \frac{T}{T_0} \sum \frac{e_k}{\beta} \right\},$$

(8)

where $I_0 = Ce\mu\tau N_i V$, $e$ is the electron charge, $\mu$ and $\tau$ are, respectively, the mobility and lifetime of free carriers, $V$ is the applied voltage, $C$ is a geometrical, $N_i$ is the trap density, $T_0$ is the starting temperature, $\beta$ is the heating rate and $e_k$ is the emission rate from the trap, given by:

$$e_k = \frac{16\pi m_k^2}{h^3} \sigma T^2 \exp \left\{ - \frac{E_{t0}}{k_BT} \right\},$$

(9)
In eq. (9) $m^*$ is the free carrier effective mass, $h$ is Planck's constant, $k_b$ is Boltzmann's constant, $\sigma$ is the free carrier capture cross-section and $E_{i0}$ is the ionization energy of the traps. Usually, the temperature dependence of $\sigma$ can be expressed as $\sigma(T) = \sigma_{i0} \exp\left(-\frac{E_{i0}}{k_bT}\right)$ and the experimentally measured trap activation energy is then $E_i = E_{i0} + E_\sigma$.

It was shown [16,17] that the integral in eq. (8) can be approximated to the following, more practical, result:

$$I_{TSC}(T) = I_0 \exp\left\{-\frac{E_i}{k_bT} - \frac{k_bD_1T^2}{E_i} e^{\frac{k_bT}{k_bT}}\right\} \times \left[1 - 4 \frac{k_bT}{E_i} + 20 \left(\frac{k_bT}{E_i}\right)^2\right]$$

(10)

where $D_1 = 2.95 \times 10^{21} (m^*/m_0)\sigma_{i0}$, with $\sigma_{i0}$ in cm$^2$, $m_0$ is the electron rest mass, the numerical factor represents the constants entering eq. (8) and $I_0 = Ce\mu\Phi_0\alpha V$.

Figure 7 shows the normalized TSC spectra measured before and, after irradiation, respectively. We have used the normalized procedure, introduced previously by Look et al., [18,19]. This procedure is based on the observation that both TSC and photocurrent $I_{PC}$ are proportional to lifetime $\tau$ and mobility $\mu$ of the carriers, and therefore, their ratio $I_{TSC}/I_{PC}$ should only depend on quantities that can be obtained by fit. In this way complete quantitative results can be extracted from TSC data. In case of thin films ($\alpha d < 1$, $\alpha$ being light absorption coefficient and $d$ the film thickness), the photocurrent is given by $I_{PC} = C\mu\Phi_0\alpha V$, where $\Phi_0$ is the incident light flux and $C$ the geometrical factor entering eq. (8). The $I_{TSC}/I_{PC}$ ratio is then given by:

$$\frac{I_{TSC}}{I_{PC}} = \frac{N_rD_1T^2}{\Phi_0\alpha} \exp\left\{-\frac{E_i}{k_bT} - \frac{k_bD_1T^2}{E_i} e^{\frac{k_bT}{k_bT}}\right\} \times \left[1 - 4 \frac{k_bT}{E_i} + 20 \left(\frac{k_bT}{E_i}\right)^2\right].$$

(11)

Fig. 7. Normalized TSC spectra, recorded before (a) and after (b) irradiation with 6 MeV, $5 \times 10^{13}$ electrons/cm$^2$. Continuous lines represent the calculated TSC spectra by simultaneous fitting, while dashed lines indicate individual TSC peaks.

Both spectra consist of several heavily overlapped peaks and a direct use of eq. (11) for any of them is not adequate. To reduce the interference of neighboring peaks, a fractional heating technique was used: after illumination the sample was heated with constant rate to a temperature
The values of the parameters $E_t$, $\sigma_0$, and $I_0$ obtained at this stage were then used as initial guess for a simultaneous fit of the spectra with sums of features given by eq. (11). In Ref. 17 it was demonstrated that this procedure minimizes errors in parameters of each peak and can indicate "missing" peaks. After this step $E_t$ and $\sigma_0$ values remained practically unchanged, while pre-exponential factors $I_0$ were modified. This was to be expected, since the repeated heating-cooling cycle modifies the initial concentrations of trapped electrons for peaks corresponding to deeper levels overlapping with analyzed ones. The trap parameters, as obtained by this procedure, are indicated in Table 4.

<table>
<thead>
<tr>
<th>Trap</th>
<th>$E_t$ (eV)</th>
<th>$N_t$ ($\text{cm}^{-3}$)</th>
<th>$\sigma_0$ ($\text{cm}^{-2}$)</th>
</tr>
</thead>
<tbody>
<tr>
<td>$D_1$</td>
<td>0.38</td>
<td>$4.79 \times 10^3$</td>
<td>$7.70 \times 10^4$</td>
</tr>
<tr>
<td>$D_2$</td>
<td>0.24</td>
<td>$7.22 \times 10^3$</td>
<td>$1.58 \times 10^4$</td>
</tr>
<tr>
<td>$D_3$</td>
<td>0.17</td>
<td>$4.31 \times 10^3$</td>
<td>$8.25 \times 10^3$</td>
</tr>
<tr>
<td>$D_4$</td>
<td>0.14</td>
<td>$1.93 \times 10^3$</td>
<td>$5.97 \times 10^3$</td>
</tr>
<tr>
<td>$D_5$</td>
<td>0.06</td>
<td>$1.03 \times 10^3$</td>
<td>$2.68 \times 10^3$</td>
</tr>
<tr>
<td>$D_6$</td>
<td>0.045</td>
<td>$7.70 \times 10^2$</td>
<td>$1.62 \times 10^3$</td>
</tr>
<tr>
<td>$D_7$</td>
<td>0.036</td>
<td>$6.20 \times 10^2$</td>
<td>$1.33 \times 10^3$</td>
</tr>
<tr>
<td>$D_8$</td>
<td>0.02</td>
<td>$2.71 \times 10^2$</td>
<td>$7.25 \times 10^2$</td>
</tr>
<tr>
<td>$D_9$</td>
<td>0.01</td>
<td>$1.20 \times 10^2$</td>
<td>$2.51 \times 10^2$</td>
</tr>
</tbody>
</table>

* as grown sample; * irradiated sample

The most important effect of electron irradiation is easily seen in the high temperature region of the spectra. The density of $D_1$ traps is larger by more than an order of magnitude after irradiation, also an important increase of $D_4$ traps density is evident.

### 4. Discussion

The experimental results obtained by various methods converged to the conclusion that electrical properties of the films prepared as described above are controlled by a main donor defect located at 0.38-0.40 eV below the conduction band. The results also clearly demonstrated that the density of those defect centers is significantly increased by irradiation with electrons having energies in MeV range.

It is difficult to establish the origin of defects identified by the above-indicated experimental procedures. This task is further complicated in the case of thin films, where local structural disorder exists at grain boundaries or surface and can lead to a broadening of otherwise well defined levels. However, the simplest defects presumably to act as deep donors in CdSe are Se-vacancies and Cd-interstitials. Such defects are also very likely to be produced by electron irradiation. The peculiarity of irradiation with high-energy (in MeV range) electrons consists in the fact that it produces a few atomic displacements. The maximum energy transferred at impact by an electron having an energy $E$ to an atom of mass $M$ is given by [20]:

$$E_m = \frac{2m_0}{M} E \left( 2 + \frac{E}{m_0 c^2} \right)$$

(12)
For an initially 6 MeV electron, the maximum energy transferred to a Cd atom is 802 eV, while for a Se atom it is 1140 eV. The exact threshold energy for atomic displacement in CdSe is unknown, to our knowledge. For other compound semiconductors, experimentally determined threshold energy ranges from about 6 eV to 12 eV (Ref. 20, p. 229). A value of 8.7 eV was measured in the case of a related compound, CdS (Ref. 9, p. 194). Assuming a displacement energy of 10 eV, each primarily knock-on atom can produce up to 50 secondary displacements. The rate of energy loss of incident electrons is of the order of 10 MeV/cm [9] and consequently the electron energy loss in our samples is negligible, which implies that the irradiation generated Frenkel (interstitial-vacancy) pairs are uniformly distributed in volume. Some of them disappear by direct recombination. But it is plausible that interstitials, having larger mobility than vacancies, will more easily migrate among vacancies, eventually being trapped by other defects at surface or grain boundaries. Consequently, some of the vacancies produced by electron irradiation will survive the recombination process. They could also form aggregates and/or interact with oxygen atoms residually present in the vacuum chamber. We infer that D\textsubscript{1} defect, which is determining electrical properties of our samples and is predominantly produced by irradiation, may be assigned to a Se-vacancy or a more complex point-like defect associated to a Se-vacancy.

5. Conclusions

We presented in this paper an investigation by various techniques on the effects of 6 MeV electron irradiation on electrical properties of CdSe thin films grown by vacuum deposition.

XRD spectra revealed that the films consist of hcp wurtzite phase, preferentially oriented with (001) crystalline direction perpendicular to their surface. Within the limits of experimental resolution, no change in diffraction pattern aspect or in line broadening was observed following electron irradiation at fluences up to \(10^{18}\) electrons/cm\(^2\). It follows then that irradiation with 6-MeV electrons results in the creation of point-like defects.

Electrical properties of the films were investigated using two different geometries, Au/CdSe/Au sandwich cells and, respectively, planar structures with four Al contacts deposited on top of the films. A model was developed in the frame of SCLC theory with a more realistic energetic distribution of traps. This model was used to the analysis of experimentally obtained I-V curves for Au/CdSe/Au sandwich cells. The results are in perfect agreement with those obtained from TSC curves measured in the case of planar structures.

An extrinsic conduction determined by the presence of a main donor center located at 0.38-0.40 eV below the conduction band bottom edge was observed in the high temperature range (room temperature and below, to 240 K). At low temperatures charge transport occurs through hopping mechanism; in that temperature range the effect of irradiation is more pronounced. The density of localized states involved in the hopping process is increased by irradiation, consequently the overlap of their corresponding wave functions increases, which results in exponentially smaller resistance values.

From TSC spectra analysis, several traps were identified in the band gap. The above mentioned deep donor D\textsubscript{1} with ionization energy of 0.38 eV, which mainly controls electrical behavior of the films, exists in larger densities. The TSC procedure we used allows for an accurate determination of trap parameters. After irradiation a significant increase of D\textsubscript{1} trap density occurred. We believe that D\textsubscript{1} is related to a Se-vacancy or to a more complex defect associated with a Se-vacancy. The origin of the other identified defects, with smaller ionization energies, remains unknown at this time.

References